



<b>INFORMATION DISCLOSURE CITATION</b>  <b>PTO-1449</b>			ATTY. DOCKET NO. 39829-0002		SERIAL NO. 09/679,321		
			APPLICANT Junaid Islam, et al.				
			FILING DATE 10/03/2000		GROUP 2152		
<b>U.S. PATENT DOCUMENTS</b>							
EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE	
<b>FOREIGN PATENT DOCUMENTS</b>							
EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
						<input type="checkbox"/>	<input type="checkbox"/>
						<input type="checkbox"/>	<input type="checkbox"/>
<b>OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)</b>							
w/	International Search Report for International Application No. PCT/US01/31007 (double-sided document).						
EXAMINER	Michael Delgado		DATE CONSIDERED		10/14/03		

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						YES	NO
<i>mm</i>	WO 02/030045 A3	11 Apr 2002	PCT			<input type="checkbox"/>	<input type="checkbox"/>
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EXAMINER	<i>mm chael dalgard</i>			DATE CONSIDERED	<i>11/14/03</i>		

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